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| To Examiner: Asok K. Sarkar | Total Pages Sent: 16 |
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| Facsimile Number: (571) 273-8300 | Transmission Date: February 28, 2006 |

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| Applicant: Low, <i>et al.</i> | Docket No.: 02 P 15173 US / INTECH 3.0-076 |
| Serial No: 10/689,233 | Art Unit: 2891 |
| Date Filed: October 20, 2003 | |
| TITLE: Inclusion Of Low-K Dielectric Material Between Bit Lines | |

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 Response Under 37 C.F.R. § 1.116 (15 pages)

Respectfully submitted,

Kristy Engeldahl
 Kristy Engeldahl
 Legal Assistant

Confirmation Respectfully Requested

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RESPONSE UNDER 37 C.F.R. § 1.116
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Low, *et al.* Docket No.: 02 P 15173 US / INTECH
3.0-076

Serial No.: 10/689,233 Art Unit: 2891

Filed: October 20, 2003 Examiner: Asok K. Sarkar

For: Inclusion Of Low-K Dielectric Material Between Bit Lines

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. § 1.116

Dear Sir:

The following remarks are presented in response to the Examiner's Final Office Action
mailed December 28, 2005.